

Supporting Information

A vapor-phase-assisted growth route for large-scale uniform deposition of MoS₂ monolayer films

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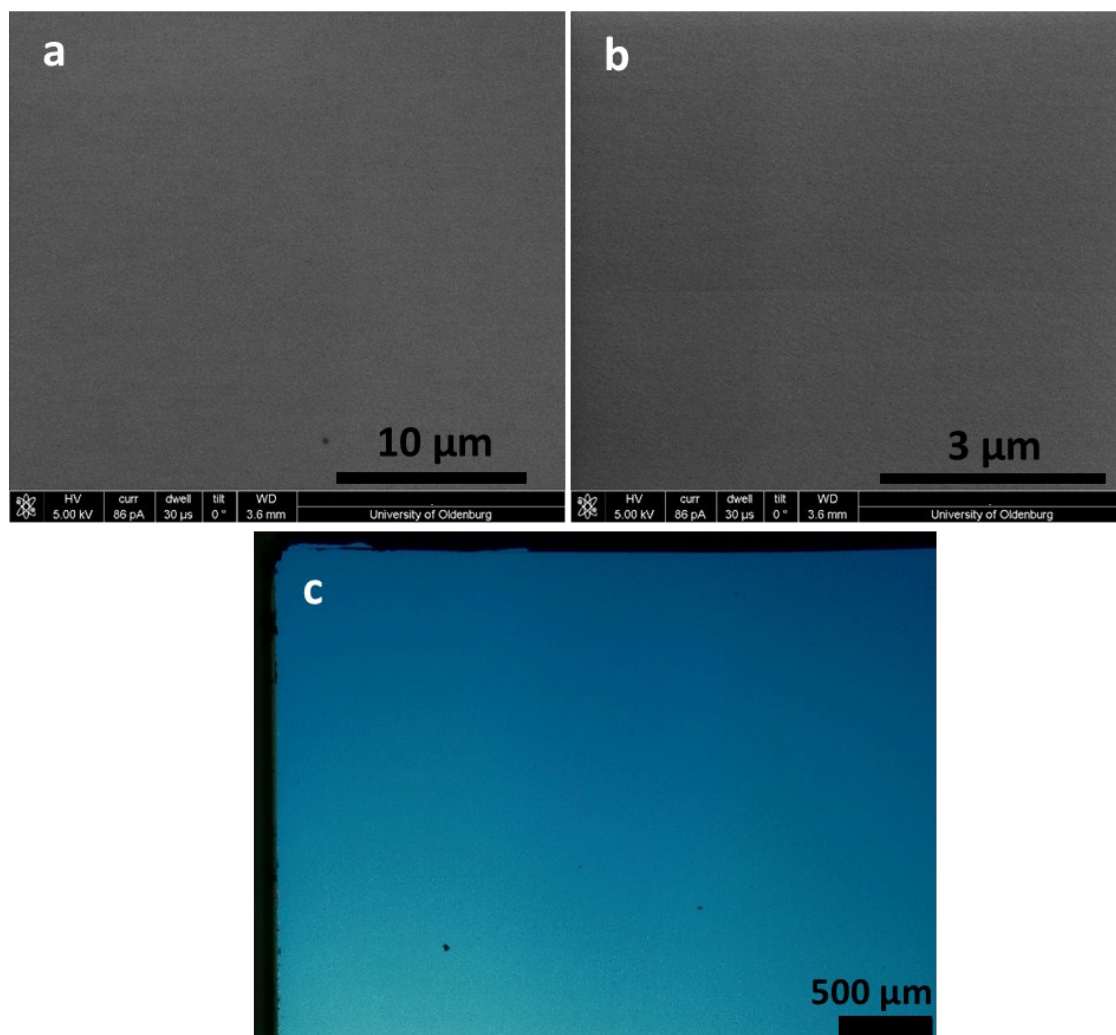


Fig. S1: SEM micrographs (a,b) and an optical overview image (c) of the sample processed at 950 °C. No visible structures are observable, indicating a homogenous deposition on the substrate with no discernible features on length scales larger than 100 nm.